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Schultz et al.

[54] BIPOLAR ELECTRODE

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[56] References Cited

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[57] **ABSTRACT**

An improved dimensionally-stable bipolar electrode for use in electrochemical processes comprising a valve metal layer, suitable anodic material on the anode side of the valve metal, a barrier layer of germanium on the cathode side of the valve metal pro-
tected by a layer of common metal cathodic material.
Such electrodes function at low hydrogen permeability rates during use in electrolytic processes.

10 Claims, No Drawings

BPOLAR ELECTRODE

This invention relates to electrodes for use in electro lytic cells. More particularly, this invention relates to improved, corrosion-resistant, dimensionally-stable bipolar electrodes particularly useful in the electrolysis of alkali metal chlorides in the production of alkali metal chlorates.

The electrolysis of aqueous solutions of alkali metal chlorides such as sodium chloride and potassium chlo- $\frac{10}{\pi}$ metal. ride has been conducted commercially for years on a

wide scale.
Graphite electrodes have been employed in the past in various alkaline chloride electrolysis operations;
have past in disolventions which $\frac{15}{15}$ however, there have been certain disadvantages which have arisen as a result of the use of graphite. One of the most serious of the disadvantages is the constant attri tion of the graphite during the electrolysis operation. Attrition results in the increase of the clearance or spacing between the anode and the cathode which in turn causes an increase in the cell voltage drop and a resulting decreasing efficiency in cell operation.

Graphite anodes have a limited life, generally being on the order of about 1.0 inches in thickness on instal lation but at the end of 10-12 months of continuous use may be reduced to about 0.25 inches, with the atten dant loss in power and efficiency. Such losses, includ ing economic losses, have resulted in the proposed use
of metallic electrodes and the use of bipolar cells. 30 of metallic electrodes and the use of bipolar cells.

Generally in the production of alkali metal chlorate, bipolar electrodes are now preferentially used which, when arranged suitably in an electrolytic cell, in a spaced electrical series, serve to function both as the anode and cathode in the cell. The electrodes are sub jected to an electrical potential while immersed in the alkali metal chloride solution and, electrochemically, alkali metal chlorate is produced, either in the cell itself, or outside the cell upon the standing of the solu-
 $\frac{1}{40}$ tion.

The advantages of the use of the bipolar cells and bi polar electrodes include:

a. bipolar cells are relatively simpler and more eco nomical to produce than are monopolar cells;

b. the electrical contact for supplying current to the 45 electrodes in bipolar cells is applied only through the first and last plates while the current supply to the an odes of monopolar cells must be supplied by electrical contact established with each individual anode;

c. bipolar cells allow for the use of minimal distances 50 between the electrodes which reduces voltage and al lows for a reduction of the volume of electrolyte used.

Platinum group metal-coated electrolytic valve met als such as titanium have been proposed as substitutes for graphite anodes. The metallic electrodes have of fered several potential advantages over conventional graphite electrodes, as for example, lower over-voltage, lower erosion rates and the resulting electrolytic production of higher purity products. The economic advantages gained by the use of such electrodes, however, must be sufficiently high to overcome the high cost of these metallic electrodes.

A problem existant with bipolar electrodes based on
hodic precious metals is that the titanium or valve 65 anodic precious metals is that the titanium or valve metal support is attacked by hydrogen during the elec trolysis on the cathode side, forming hydrides and caus ing disintegration of the electrode.

The present invention provides a bipolar electrode having excellent electrolytic use characteristics and ex cellent durability. The electrodes of the present inven tion are composite bipolar electrodes having a base layer of valve metal, preferably titanium, an anodic ma terial, preferably a platinum group metal or metal ox ide, deposited on one side of the valve metal, and a bar rier layer of germanium on the opposing side of the valve metal, overlaid with a layer of suitable cathodic

20 trons. The electrode comprises a central or inner layer of a valve metal of which the oxide is chemically resistant under anodic conditions to the electrolyte emploved. The expression "valve metal" as employed herein is definitive of a metal which can function generally as a cathode in an electrolytic cell, but not generally as an anode, due to the formation, under anodic conditions, is highly resistant to the passage therethrough of elec-

The preferred valve metal is titanium, although tanta lum, or colombium may also be advantageously em ployed.

²⁵ conditions" hereinbefore employed, as applied to the The expression 'chemically resistant under anodic valve metal, indicates that the oxide is resistant to the corrosive surrounding electrolyte and is not, to an appreciable extent subject to erosion, deterioration ot to electrolyte attack.

The germanium has a low hydrogen diffusion rate and effectively prevents the migration of cathodically produced hydrogen from reaching the surface of the valve metal.

One face of the central or inner valve metal layer is adhered to a layer of germanium. The valve metal may be adhered to the germanium layer by any means readily available in the art, particularly by sputtering the germanium onto the valve metal. The thickness of the layers is not critical, it only being necessary that the thickness of the titanium or other valve metal central or inner layer furnish a self supporting layer, and that the layer of germanium be of such thickness and cha racterisitcs as to provide an essentially hydrogen imper-
meable barrier layer. Generally, the valve metal layer is on the order of from about 0.01 inch to about 0.70 or 0.80 inches in thickness, with the layer of the germanium being on the order of from about 0.01 inch in thickness to up to about 0.1 inch in thickness, if de sired.

At least an operable portion of the opposing face of the central or inner layer has bonded thereto a layer of suitable anodic material chemically resistant under an odic conditions to the electrolyte used. The term "suit 55 60 able anodic material' as employed herein refers to a material which is electrically conductive, resistant to oxidation and substantially insoluble in the electrolyte. Platinum is the preferred anodic material; however, it is also possible to utilize ruthenium, palladium, os mium, iridium, oxides of these materials, alloys of two or more of the metals, or suitable mixtures thereof.

The cathodic material, or outer cathode side layer, may be of any suitable, common cathodic material
chemically resistant or insoluble in the electrolyte under cathodic conditions. Such materials as steel, copper, chromium, cobalt, nickel, iron, or alloys of these plied to the germanium layer by any suitable means

known to the art which is nondestructive to the germa-
nium layer, e.g., electroplating, vacuum deposition, metal spraying or the like. The thickness of the ca thodic material layer may vary, but the material is gen erally utilized as a thin film, about 0.01 inch in thickness or greater.

The anodic material, preferably platinum, can be applied to the anodic side of the valve metal by using such sources of platinum as chloroplatinic acid or a thermally-decomposable metallo-organic compound 10 such as a platinum resinate.

For example, the metallic resinate may be mixed with an organic solvent or diluent, such as terpenes or aro matics, typically oil of turpentine, xylene or toluene. before being applied to the base member. The elec trode is heated to decompose and/or to volatilize the organic matter and other non-metallic components, leaving on the base member a layer of adherent electroconductive platinum. In producing a metallic anodic coating by such method, care should be taken to avoid oxide formation, for example, by limiting the tempera tures of heating or by effecting heating in an oxygen free atmosphere such as in a vacuum or under a nitro gen or argon blanket.

Heating may be effective in an air atmosphere; how- 25 ever, temperatures above about 600-650°C are not recommended due to the possibility of oxidizing the valve metal.

In the production of an anodic oxide coating, the monographical state $\frac{30}{20}$ temperatures and time of heating are selected that will result in the formation of an oxide, preferably an oxide of a metal of the platinum series of metals, such as ru thenium. The temperature applied may vary depending upon the particular platinum metal used. Typically, the tamentum may be in the range of from about 300° to 35° temperature may be in the range of from about 300° to about 600°C, preferably from about 350°C to about 550°C, with such temperatures applied for periods on the order of from about 10 minutes to about 2 hours. The heating of the metal is most advantageously con ducted in an atmosphere containing elemental oxygen such as air or other oxygen-inert gas mixtures although an atmosphere or pure oxygen could be used. The plati num group metal oxide formed is either crystalline or amorphous depending upon the temperature of heating. with the degree of crystallinity increasing as tem peratures and duration of heating are increased. Both crystalline, particularly if the crystals are small in size, and non-crystalline coatings have good electroconduc tivity. Where the coatings have a low degree of crystal times.

It is not necessary that the anodic material be applied in such a manner as to completely cover the entire sur face of the valve metal central or inner layer. However, the total anodic side of the central or inner layer should be coated with the anodic material to the cxtent that the massed portion of the anodic material function ef fectively as an anode. It is preferred that the anodic ma terial essentially cover the anodic side of the valve

metal layer.
The anodic layer, preferably a platinum group metal or metal oxide, can be deposited to the extent of 0.0001 inch, although the use of lesser or greater thick nesses may be achieved, depending on the methods of deposition, it only being necessary that the anodic ma- 65 terial be present on the anodic side of the central or inner layer in an amount sufficient to function effec tively as the anode. 60

5 The anodic material, as hereinbefore stated, can be deposited on the central or inner layer of valve metal
by any suitable method known to the art. The deposition can be effected, for example, by using a bath consisting of 4.5 grams platinic chloride and 22 ml 37 percent hydrochloric acid dissolved in 2,800 ml water. The temperature is generally maintained between 70° and 85°C and the current intensity is such that essentially no hydrogen is evolved at the valve metal panel. A graphite anode is used in the bath and the valve metal is made cathodic. The panel is agitated or moved dur ing the plating operation, and the current is regulated as to preclude hydrogen involvement at the valve metal, with the anodic platinum metal being deposited at a thickness less than about 0.000 l inch. Minor varia tions may be effected in the deposition of the precious metal and varying thicknesses may be obtained by suit able modifications in the time consumed in the electro plating operation. Also, simultaneous deposition may be made of more than one component, as for example, by effecting a coating from a solution containing, in addition to platinum, another platinum group metal com pound such as ruthenium, such other component being added to the electroplating bath whereby a desired re sulting composite coating is obtained by the electrode position.

40 in accordance with methods known in the art. The electrodes of the present invention, as stated, find particular application in the electrolytic produc tion of alkali metal chlorates. In producing chlorates using the electrodes of the present invention, the pro cess may be carried out continuously by passing a solu tion containing alkali metal chloride through the cells at temperatures generally on the order of up to the boil ing point of the electrolyte with the effluent liquor cooled or concentrated to promote crystallization of the chlorate produced in the cell. Advantageously, a fed to the cell in order to promote chlorate formation,

A typical bipolar electrolytic unit which can be used with the novel electrodes of the present invention con sists of a housing having spaced-apart end electrodes with the enclosed space defined by the walls and end electrodes divided intermediate at intervals by the bi polar electrodes into substantially isolated unit cells. For each individual electrolysis cell, there is an individ ual reaction zone and an individual electrolysis zone substantially isolated from the reaction and electrolysis zones of the adjoining cells, the term "unit cell' refer ring to one of the chambers or sections into which the apparatus is divided by the bipolar electrodes. Such cell makeup permits of good circulation of the electrolyte between the zones.

A bipolar electrolytic cell utilizing the bipolar elec trodes described has essentially minimal or no current leakage and voltages on the order of 3.8 to 4.0 volts can be employed, with a current density of about 4 amp/in^2 . What is claimed is:

1. A bipolar electrode consisting of a core of a valve metal, at least a portion of the anodic surface of which is conductively covered by at least one anodic material selected from platinum group metals and platinum group metal oxides, and a barrier layer of germanium on the cathodic side of the valve metal core, at least a portion of the exterior surface of the layer of germanium being covered by at least one cathodic material selected from iron, copper, cobalt, nickel and alloys of the cathodic material is iron.

2. A bipolar electrode as defined by claim 1 wherein the valve metal is titanium.

3. A bipolar electrode as defined by claim 2 wherein 5 the anodic metal is platinum metal.

4. A bipolar electrode as defined by claim 3 wherein 4. A bipolar electrode as defined by claim 5 wherein
the cathodic metal is iron.
5. A bipolar electrode as defined by claim 1 wherein
5. A bipolar electrode as defined by claim 1 wherein

5. A bipolar electrode as defined by claim 2 wherein the anodic material is ruthenium oxide.
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 $\frac{1}{2}$ the anodic material is ruthenium oxide.

6. A bipolar electrode as defined by claim 5 wherein

these.

2. A bipolar electrode as defined by claim 1 wherein

2. A bipolar electrode as defined by claim 1 wherein

the anodic material is platinum metal.

8. A bipolar electrode as defined by claim 1 wherein the cathodic metal is nickel.

9. A bipolar electrode as defined by claim 1 wherein

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